

Form PTO 1449  
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## LIST OF REFERENCES CITED BY APPLICANT

APPLICANT

Tadaaki KANEKO, et al.

FILING DATE

February 1, 2006

GROUP

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
/JL/	AA	5 383 981	01/24/95	DE PRUNEDA, Jean A. H			
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						
	AL						
	AM						

## FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	TRANSLATION	
					YES	NO
/JL/	AN	6-49619	02/22/94	JP (equivalent of US5 372 655)		NO
/JL/	AO	56-79449	06/30/81	JP (equivalent of US4 333 226)		NO
/JL/	AP	6-87656	03/29/94	JP		NO
/JL/	AQ	2000-44222	02/15/00	JP		NO
/JL/	AR	8-64110	03/08/96	JP		NO
/JL/	AS	7-330351	12/19/95	JP		NO
/JL/	AT	10-245285	09/14/98	JP		NO
/JL/	AU	2000-265274	09/26/00	JP		NO
/JL/	AV	11-116399	04/27/99	JP		NO

## OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)

/JL/	AW	ROCHER, M. et al., "Modelling of the growth of carbide layers in tantalum", Key Engineering Materials, Vols. 206-213, Part 1, Pages 527-530, 2002.				
/JL/	AX	KHARATYAN, S.L. et al., "Kinetics of Tantalum Carbideization", Soviet Journal of Chemical Physics, Vol. 8, Part 8, Pages 1881-1892, 1991.				
/JL/	AY	TSUTSUMOTO, Takahiro et al., "Improvement of Ta filament for diamond CVD", Thin Solid Films, Vol. 317, Pages 371-375, 1998.				
	AZ				<input type="checkbox"/> Additional References sheet(s) attached	

Examiner

/Jonathan Langman/

Date Considered

12/22/2009

\*Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /JL/